

<b>Electronic Patent Application Fee Transmittal</b>				
<b>Application Number:</b>	10766053			
<b>Filing Date:</b>	28-Jan-2004			
<b>Title of Invention:</b>	Method for N+ doping of amorphous silicon and polysilicon electrodes in deep trenches			
First Named Inventor/Applicant Name:	Moritz Haupt			
<b>Filer:</b>	Benjamin Nise/Natalie Swider			
<b>Attorney Docket Number:</b>	2003 P 51718 US			
Filed as Large Entity				
<b>Utility Filing Fees</b>				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
<b>Basic Filing:</b>				
<b>Pages:</b>				
<b>Claims:</b>				
<b>Miscellaneous-Filing:</b>				
<b>Petition:</b>				
<b>Patent-Appeals-and-Interference:</b>				
<b>Post-Allowance-and-Post-Issuance:</b>				
<b>Extension-of-Time:</b>				

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
<b>Miscellaneous:</b>				
Request for continued examination	1801	1	790	790
<b>Total in USD (\$)</b>				<b>790</b>